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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of

CHEVALIER et al

Atty. Ref.: 5215-2; Confirmation No. 7840

Appl. No. 10/557,695

TC/A.U. 1792

Filed: December 22, 2005

Examiner: Alejandro Mulero, Luz L

For: A HIGH DENSITY PLASMA REACTOR

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November 16, 2009

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**RESPONSE (INCLUDING AMENDMENT OF JUNE 15, 2009)**

In response to the Office Action dated October 28, 2009, applicant submits the following response (which includes the claim Amendments in applicant's Amendment dated June 15, 2009 – that may not yet be entered, which applicant assumes from a review of the Office Action of October 28).

The Commissioner is hereby authorized to charge any deficiency, or credit any overpayment, in the fee(s) filed, or asserted to be filed, or which should have been filed herewith (or with any paper hereafter filed in this application by this firm) to our Account No. 14-1140.